

CPC**COOPERATIVE PATENT CLASSIFICATION****C23F**

NON-MECHANICAL REMOVAL OF METALLIC MATERIAL FROM SURFACE (working metal by laser beams [B23K 26/00](#); desurfacing by applying flames [B23K 7/00](#); working of metal by electro-erosion [B23H](#); producing decorative effects by removing surface material, e.g. by engraving, by etching, [B44C 1/22](#); electrolytic etching or polishing [C25F](#)); **INHIBITING CORROSION OF METALLIC MATERIAL OR INCRUSTATION IN GENERAL; MULTI-STEP PROCESSES FOR SURFACE TREATMENT OF METALLIC MATERIAL INVOLVING AT LEAST ONE PROCESS PROVIDED FOR IN CLASS [C23](#) AND AT LEAST ONE PROCESS COVERED BY SUBCLASS [C21D](#) OR [C22F](#) OR CLASS [C25](#).**

NOTE

protective layers or coating compositions or methods of applying them; these are classified in the appropriate places, e.g. [B05](#), [B44](#), [C09D](#), [C23C](#).

mechanical devices or constructional features of particular articles for inhibiting incrustation; these are classified in the appropriate places, e.g. in pipes or pipe fittings [F16L 58/00](#).

articles characterised by being made of materials selected for their properties of resistance to corrosion or incrustation; these are classified in the appropriate places, e.g. turbine blades [F01D 5/28](#).

C23F 1/00

Etching metallic material by chemical means (manufacture of printing surfaces [B41C](#); manufacture of printed circuits [H05K](#))

C23F 1/02

. Local etching

C23F 1/04

.. Chemical milling

C23F 1/06

. Sharpening files

C23F 1/08

. Apparatus, e.g. for photomechanical printing surfaces (photo- mechanical reproduction [G03F](#))

C23F 1/10

. Etching compositions ([C23F 1/44](#) takes precedence)

C23F 1/12

.. Gaseous compositions

C23F 1/14

.. Aqueous compositions

C23F 1/16

... Acidic compositions ([C23F 1/42](#) takes precedence)

C23F 1/18

.... for etching copper or alloys thereof

C23F 1/20

.... for etching aluminium or alloys thereof

C23F 1/22

.... for etching magnesium or alloys thereof

C23F 1/26

.... for etching refractory metals

C23F 1/28

.... for etching iron group metals

- C23F 1/30 for etching other metallic material
- C23F 1/32 . . . Alkaline compositions ([C23F 1/42](#) takes precedence)
- C23F 1/34 for etching copper or alloys thereof
- C23F 1/36 for etching aluminium or alloys thereof
- C23F 1/38 for etching refractory metals
- C23F 1/40 for etching other metallic material
- C23F 1/42 . . . containing a dispersed water-immiscible liquid

- C23F 1/44 . Compositions for etching metallic material from a metallic material substrate of different composition

- C23F 1/46 . Regeneration of etching compositions

C23F 3/00 Brightening metals by chemical means

- C23F 3/02 . Light metals
- C23F 3/03 . . with acidic solutions

- C23F 3/04 . Heavy metals
- C23F 3/06 . . with acidic solutions

C23F 4/00 Processes for removing metallic material from surfaces, not provided for in group [C23F 1/00](#) or [C23F 3/00](#)

- C23F 4/02 . by evaporation

- C23F 4/04 . by physical dissolution

C23F 11/00 Inhibiting corrosion of metallic material by applying inhibitors to the surface in danger of corrosion or adding them to the corrosive agent ([adding inhibitors to mineral oil, fuels, or lubricants C10](#); [adding inhibitors to pickling solutions C23G](#))

- C23F 11/02 . in air or gases by adding vapour phase inhibitors

- C23F 11/04 . in markedly acid liquids

- C23F 11/06 . in markedly alkaline liquids

- C23F 11/08 . in other liquids
- C23F 11/10 . . using organic inhibitors

NOTE

A compound is classified in the last appropriate place.

Esters or anhydrides of organic acids are classified as the relevant acid unless otherwise indicated. Salts of a compound with an inorganic compound are classified as that compound unless specifically provided for.

C23F 11/12	...	Oxygen-containing compounds
C23F 11/122	Alcohols; Aldehydes; Ketones
C23F 11/124	Carboxylic acids
C23F 11/126	Aliphatic acids
C23F 11/128	Esters of carboxylic acids
C23F 11/14	...	Nitrogen containing compounds
C23F 11/141	Amines; Quaternary ammonium compounds
C23F 11/142	Hydroxy amines
C23F 11/143	Salts of amines
C23F 11/144	Aminocarboxylic acids
C23F 11/145	Amides; N-substituted amides
C23F 11/146	containing a multiple nitrogen-to-carbon bond
C23F 11/147	containing a nitrogen-to-oxygen bond
C23F 11/148	containing a nitrogen-to-nitrogen bond
C23F 11/149	Heterocyclic compounds containing nitrogen as hetero atom
C23F 11/16	...	Sulfur containing compounds
C23F 11/161	Mercaptans
C23F 11/162	Thioaldehydes; Thioketones
C23F 11/163	Sulfonic acids
C23F 11/164	containing a -SO ₂ -N group
C23F 11/165	Heterocyclic compounds containing sulfur as hetero atom
C23F 11/167	...	Phosphorus-containing compounds
C23F 11/1673	Esters of phosphoric or thiophosphoric acids
C23F 11/1676	Phosphonic acids
C23F 11/173	...	Macromolecular compounds
C23F 11/18	..	using inorganic inhibitors
C23F 11/181	...	Nitrogen containing compounds
C23F 11/182	...	Sulfur, boron or silicon containing compounds
C23F 11/184	...	Phosphorous, arsenic, antimony or bismuth containing compound
C23F 11/185	...	Refractory metal-containing compounds
C23F 11/187	...	Mixtures of inorganic inhibitors
C23F 11/188	containing phosphates
C23F 13/00		Inhibiting corrosion of metals by anodic or cathodic protection
C23F 13/005	.	{ Anodic protection }

- C23F 13/02 . cathodic; Selection of conditions, parameters or procedures for cathodic protection, e.g. of electrical conditions
- C23F 13/04 .. Controlling or regulating desired parameters
- C23F 13/06 .. Constructional parts, or assemblies of cathodic-protection apparatus
- C23F 13/08 ... Electrodes specially adapted for inhibiting corrosion by cathodic protection; Manufacture thereof; Conducting electric current thereto
- C23F 13/10 Electrodes characterised by the structure ([C23F 13/16 takes precedence](#))
- C23F 13/12 Electrodes characterised by the material ([C23F 13/16 takes precedence](#))
- C23F 13/14 Material for sacrificial anodes
- C23F 13/16 Electrodes characterised by the combination of the structure and the material
- C23F 13/18 Means for supporting electrodes
- C23F 13/20 Conducting electric current to electrodes
- C23F 13/22 Monitoring arrangements therefor

- C23F 14/00** **Inhibiting incrustation in apparatus for heating liquids for physical or chemical purposes** ([adding scale preventives or removers to water C02F 5/00](#)) { [inhibiting incrustation in polymerisation reactors C23F 15/005](#) }

- C23F 14/02 . by chemical means

- C23F 15/00** **Other methods of preventing corrosion or incrustation**

- C23F 15/005 . { [Inhibiting incrustation](#) }

- C23F 17/00** **Multi-step processes for surface treatment of metallic material involving at least one process provided for in class [C23](#) and at least one process covered by subclass [C21D](#) or [C22F](#) or class [C25](#) ([C23C 28/00 takes precedence](#))**

- C23F 2201/00** **Type of materials to be protected by cathodic protection**

- C23F 2201/02 . Concrete, e.g. reinforced

- C23F 2213/00** **Aspects of inhibiting corrosion of metals by anodic or cathodic protection**

- C23F 2213/10 . Controlling or regulating parameters
- C23F 2213/11 .. for structures subject to stray currents

- C23F 2213/20 . Constructional parts or assemblies of the anodic or cathodic protection apparatus
- C23F 2213/21 .. combining at least two types of anodic or cathodic protection
- C23F 2213/22 .. characterized by the ionic conductor, e.g. humectant, hydratant or backfill

- C23F 2213/30 . Anodic or cathodic protection specially adapted for a specific object

- C23F 2213/31 . . Immersed structures, e.g. submarine structures
- C23F 2213/32 . . Pipes